Application No. National Phase of PCT/DE2004/002679 Amendment dated June 23, 2006 First Preliminary Amendment

•

Docket No.: 30572/41894

AMENDMENTS TO THE CLAIMS

- 1. (Currently amended) MetalA metal-containing, hydrogen-storing material that contains [[a]]an organometallic compound as a catalyst for hydrating or dehydrating the same.
- 2. (Currently amended) Metal metal-containing material according to claim 1, characterised in that wherein the organometallic compound is liquid.
- 3. (Currently amended) Metal A metal-containing material according to one of claims 1 or 2, characterised in that this claim 1 wherein the material displays a nanocrystalline structure.
- 4. (Currently amended) Metal-A metal-containing material according to one of the preceding claims, characterised in that claim 1, wherein the organometallic compound displays a nanocrystalline structure.
- 5. (Currently amended) Metal-A metal-containing material according to one of the preceding claims, characterised in that claim 1, wherein the organometallic compound content lies in the region between 0.005 mol% and 50 mol%.
- 6. (Currently amended) Metal-A metal-containing substance-material according to claim 5, characterised in that wherein the organometallic compound content lies in the region between 0.005 mol% and 20 mol%.
- 7. (Currently amended) Method A method for the manufacture of a metal-containing material according to one of the preceding claims, characterised in that claim 1, wherein the metal-containing material [[with]]containing the organometallic compound is subjected to a mechanical grinding process.
- 8. (Currently amended) Method A method according to claim 7, characterised in that wherein the duration of the grinding process is 1 minute to 200 hours.

First Preliminary Amendment

9. (Currently amended) Method A method according to claim 8, characterised in that wherein the duration of the grinding process lies in the region from 20 hours to 100 hours.

- (Currently amended) Method-A method according to one of claims 7-to 9, characterised in that claim 7 wherein the grinding process is performed in an inert gas atmosphere.
- (Currently amended) Method A method according to claim 10, characterised in that wherein the inert gas is argon.
- 12. (Currently amended) Method A method according to one of claims 7 to 11, eharacterised in that claim 7 wherein the grinding process is performed with the addition of an organic solvent.
- 13. (New) A metal-containing material according to claim 2, wherein the material displays a nanocrystalline structure.
- 14. (New) A metal-containing material according to claim 2, wherein the organometallic compound content lies in the region between 0.005 mol% and 50 mol%.
- 15. (New) A metal-containing material according to claim 4, wherein the organometallic compound content lies in the region between 0.005 mol% and 50 mol%.
- 16. (New) A method according to claim 9, wherein the grinding process is performed in an inert gas atmosphere.
- (New) A method according to claim 8, wherein the grinding process is performed with the addition of an organic solvent.
- 18. (New) A method according to claim 9, wherein the grinding process is performed with the addition of an organic solvent.

Application No. National Phase of PCT/DE2004/002679 Amendment dated June 23, 2006 First Preliminary Amendment

19. (New) A method according to claim 10, wherein the grinding process is performed with the addition of an organic solvent.

Docket No.: 30572/41894

20. (New) A method according to claim 11, wherein the grinding process is performed with the addition of an organic solvent.

5